

| Т | Application No. | Applicant(s) |
|---|--------------------|----------------|
| | 10/068,283 | SCHERER ET AL. |
| Γ | Examiner | Art Unit |
| | Rodney G. McDonald | 1753 |

| SEARCHED | | | | | | |
|------------|----------|----------|----------|--|--|--|
| Class | Subclass | Date | Examiner | | | |
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| 204 | 192.12 | 6/3/04 | M | | | |
| 204 204 | 192.14 | <i>'</i> | | | | |
| 430 | 494 | | | | | |
| 427 | 255.11 | 6/3/04 | m | | | |
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| INT | INTERFERENCE SEARCHED | | | | | |
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| Class | Subclass | Date | Examiner | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | | |
|---|--------|------|--|--|--|
| | DATE | EXMR | | | |
| EAST: silicon; silicone elestomer: RTV | 6/3/04 | phi | | | |
| elastomer: RTV sputter & reactive sputter & photolithograph & surface tension | | | | | |
| surface tension pesin | c/3/04 | m | | | |
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